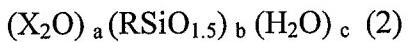
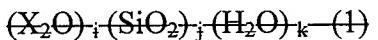


Appl. No.: 10/808,692  
Amdt. dated September 19, 2007  
Reply to Office Action of June 25, 2007

Amendments to the Claims:

1. (Currently Amended) A composition for forming a porous film comprising a condensation product and an organic solvent wherein the condensation product is obtained by adding acid to at least one ~~compound selected from the group consisting of silicate represented by formula (1) and organosilicate represented by formula (2)~~



wherein X independently represents Li, Na, K, Rb, Cs or quaternary ammonium; ~~i, j and k independently represent numbers which satisfy  $0 < i \leq 1$ ,  $0 < j \leq 1$  and  $0 \leq k \leq 2$~~ ; R independently represents a hydrogen atom or an organic group; and a, b and c independently represent numbers which satisfy  $0 < a \leq 1$  and  $0 < b \leq 1$  and  $0 \leq c \leq 1.5$ .

2. (Original) The composition for forming a porous film according to Claim 1 wherein said quaternary ammonium comprises an alkyl group having 1 to 20 carbons.

3. (Original) The composition for forming a porous film according to Claim 1 wherein said R represents an organic group having 1 to 10 carbons.

4. (Currently Amended) The composition for forming a porous film according to Claim 1 wherein ~~said silicate represented by formula (1) is tetramethylammonium silicate and said organosilicate represented by formula (2) is tetramethylammonium methylsilicate~~.

5. (Previously Presented) A method for manufacturing a porous film comprising steps of applying a composition according to Claim 1 to a substrate so as to form a film thereon, drying the film and heating the dried film so as to harden the film.

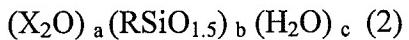
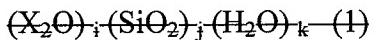
6-12. (Cancelled)

Appl. No.: 10/808,692  
Amdt. dated September 19, 2007  
Reply to Office Action of June 25, 2007

13. (Previously Presented) The composition for forming a porous film according to Claim 1, wherein the composition is capable of forming a porous film having a modulus of elasticity of 5 to 50 GPa.

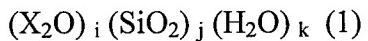
14. (Previously Presented) The composition for forming a porous film according to Claim 1, wherein the composition is capable of forming a porous film having a dielectric constant of 2.3 or less.

15. (Currently Amended) A composition for forming a porous film comprising a condensation product and an organic solvent wherein the condensation product is obtained by adding acid to at least one ~~compound selected from the group consisting of silicate represented by formula (1) and organosilicate represented by formula (2)~~



wherein X independently represents Li, Na, K, Rb, Cs or quaternary ammonium; i, j and k independently represent numbers which satisfy  $0 < i \leq 1$ ,  $0 < j \leq 1$  and  $0 \leq k \leq 2$ ; R independently represents a hydrogen atom or an organic group; and a, b and c independently represent numbers which satisfy  $0 < a \leq 1$  and  $0 < b \leq 1$  and  $0 \leq c \leq 1.5$ , and wherein the condensation product and the organic solvent are in the form of a coating liquid that is capable of being applied as a film with a spin coater.

16. (New) The composition for forming a porous film according to Claim 1 wherein said condensation product is obtained by adding acid to said organosilicate and at least one silicate represented by formula (1)

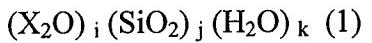


wherein X independently represents Li, Na, K, Rb, Cs or quaternary ammonium and i, j and k independently represent numbers which satisfy  $0 < i \leq 1$ ,  $0 < j \leq 1$  and  $0 \leq k \leq 2$ .

17. (New) The composition for forming a porous film according to Claim 16, wherein said silicate is tetramethylammonium silicate.

Appl. No.: 10/808,692  
Amdt. dated September 19, 2007  
Reply to Office Action of June 25, 2007

18. (New) The composition for forming a porous film according to Claim 15 wherein said condensation product is obtained by adding acid to said organosilicate and at least one silicate represented by formula (1)



wherein X independently represents Li, Na, K, Rb, Cs or quaternary ammonium and i, j and k independently represent numbers which satisfy  $0 < i \leq 1$ ,  $0 < j \leq 1$  and  $0 \leq k \leq 2$ .

19. (New) The composition for forming a porous film according to Claim 18, wherein said silicate is tetramethylammonium silicate.